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INFC	RMATION	DISCLO	SUBFE	ATTORNEY'S DKT NO. 025219-268		APPLICATION NO. 09/600,590	
INFORMATION DISCLOSURE 025219-268 09/600,590 CITATION Bernard Aspar, et al.							
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PTO-1449				July 19, 2000		Unassigned	
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EXAMINER'S	DATENT NO	DATE	NAME		CLASS	SUBCLASS	FILING DATE
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.